

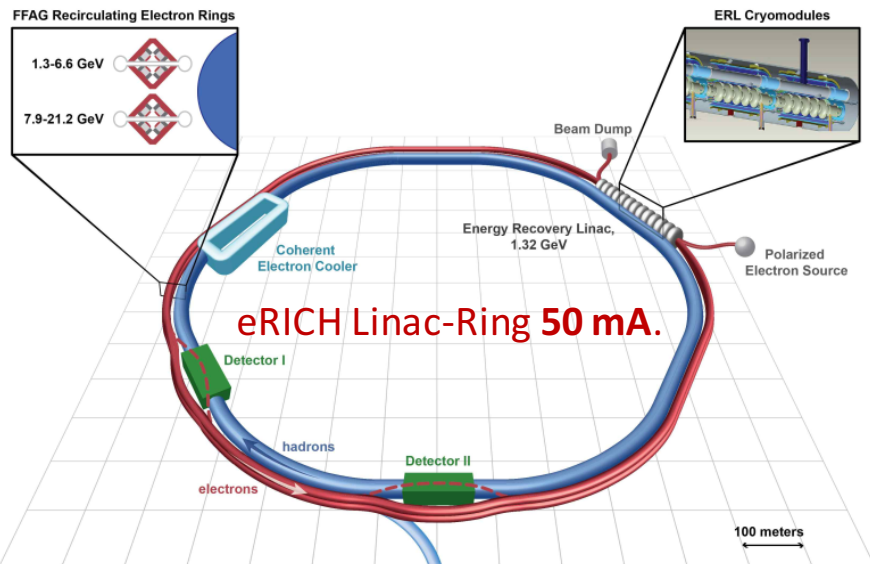


High current polarized electron sources development

Luca Cultrera



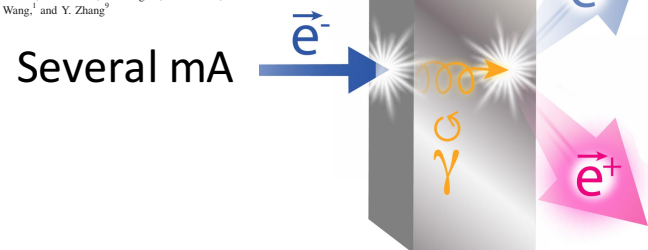
- Spin polarized photocathode requirements;
- State-of-the-art of GaAs-based photocathodes;
- Photoemission R&D at Cornell University;
- Cs_2Te and Cs_3Sb activated GaAs;
- Outlook and future work;



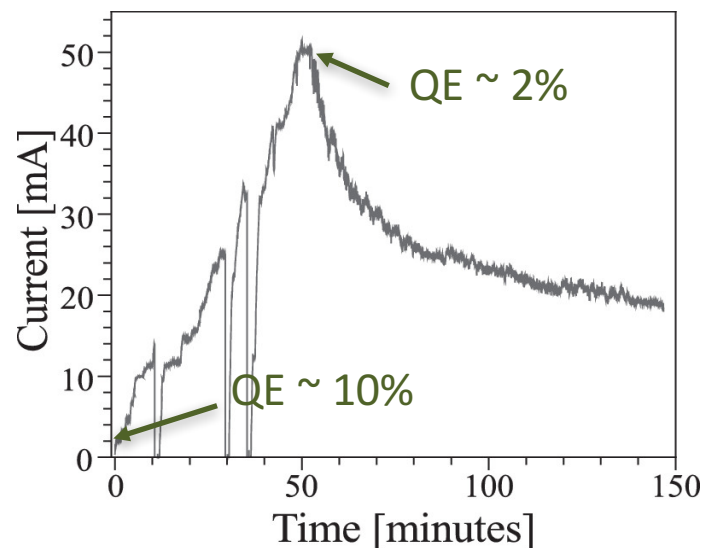
PRL 116, 214801 (2016) PHYSICAL REVIEW LETTERS week ending 27 MAY 2016

Production of Highly Polarized Positrons Using Polarized Electrons at MeV Energies

D. Abbott,¹ P. Adderley,¹ A. Adeyemi,² P. Aguilera,¹ M. Ali,¹ H. Areti,¹ M. Baylac,² J. Benesch,¹ G. Bosson,² B. Cade,¹ A. Camsonne,¹ L. S. Cardman,¹ J. Clark,¹ P. Cole,⁴ S. Covert,¹ C. Cuevas,¹ O. Dadoun,² D. Dale,² H. Dong,¹ J. Dumas,^{1,2} E. Fanchini,¹ T. Forest,⁴ E. Forman,¹ A. Freyberger,¹ E. Froidefond,² S. Golge,¹ J. Grames,¹ P. Guèye,¹ J. Hansknecht,¹ P. Harrell,¹ J. Hoskins,¹⁰ C. Hyde,¹ B. Josey,¹ R. Kazimi,¹ Y. Kim,^{1,11} D. Machie,¹ K. Mahoney,¹ R. Mammeli,¹ M. Marton,¹ J. McCarter,¹¹ M. McCaughan,¹ M. McHugh,¹⁴ D. McNulty,¹ K. E. Mesick,² T. Michaelides,¹ R. Michaels,¹ B. Moffitt,¹ D. Moser,¹ C. Muñoz Camacho,⁴ J.-F. Muraz,² A. Oppen,¹² M. Poelker,¹ J.-S. Réal,² L. Richardson,¹ S. Setiniyaz,⁴ M. Stutzman,¹ R. Suleiman,¹ C. Tennant,¹ C. Tsai,¹² D. Turner,¹ M. Ungaro,¹ A. Variola,² E. Voutier,^{2,6,*} Y. Wang,¹ and Y. Zhang⁹

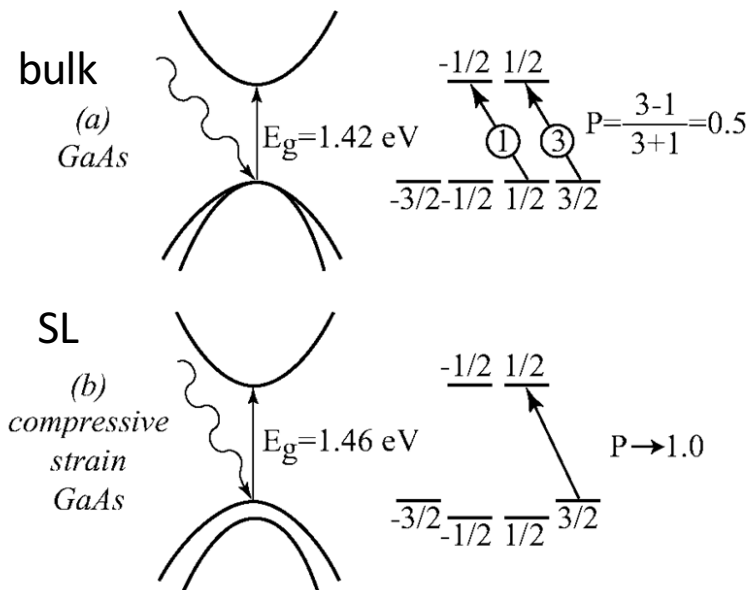


GaAs @ 532 nm (~5 Watts)
200 Coulomb

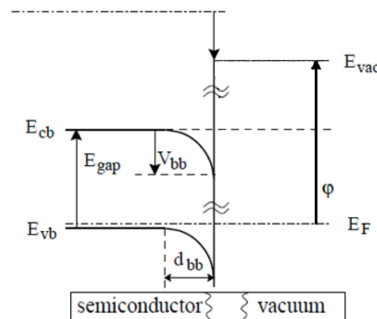


B. Dunham et al, Appl. Phys. Lett. **102**,034105 (2013)

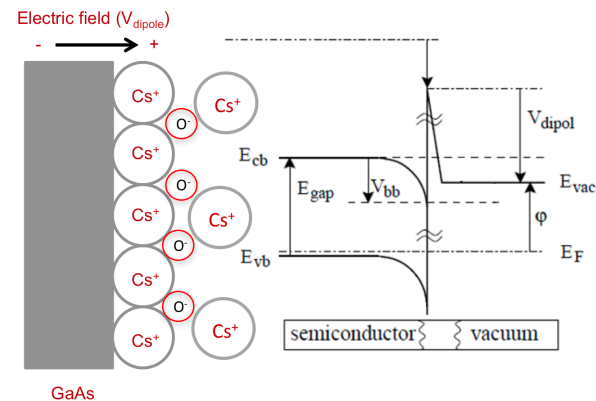
At **typical 1% QE** the required laser power “on the cathode”
@800 nm to generate **50 mA** is about **7 Watts**



Before Activation



**After Activation
(NEA)**

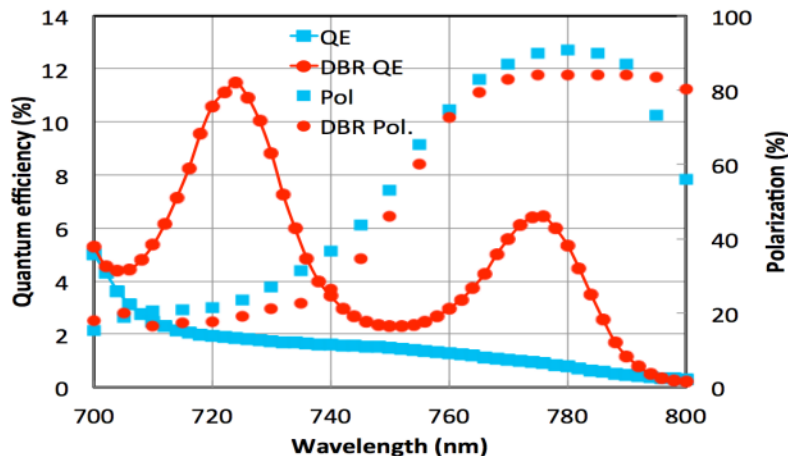


All GaAs based photocathodes requires Cs-O activation to achieve Negative Electron Affinity (NEA) and vacuum levels better than 10^{-11} Torr to survive a few days (without even running the beam)

- *Total laser absorption in the SL layer is usually <5%*
- *A DBR can be used to reflect the transmitted laser beam back to the SL*

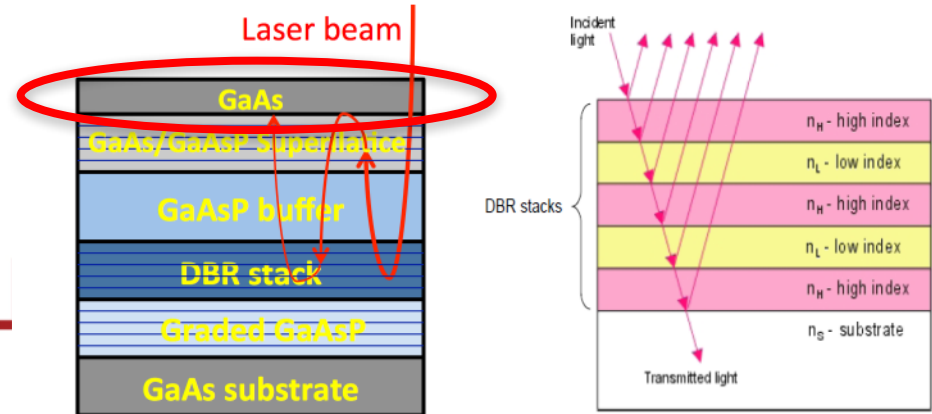
Experimental Results

- non-DBR: QE ~ 0.89%, Pol ~ 92% @ 776 nm:
 - DBR: Pol. ~ 84%, QE ~ 6.4%, Enhancement: ~7.2



Benefits of DBR

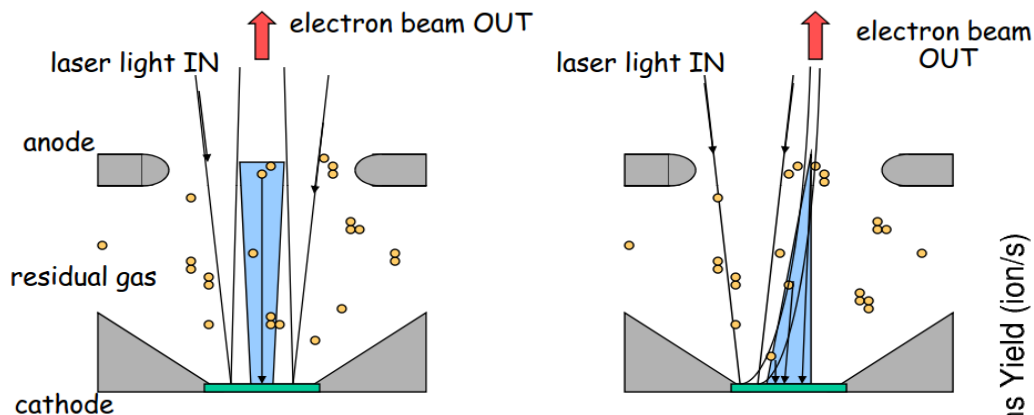
- DBR photocathode : absorpt. in GaAs/GaAsP SL >20%
Less light needed \Rightarrow less heat deposited
- F-P can be formed btw top layer & DBR



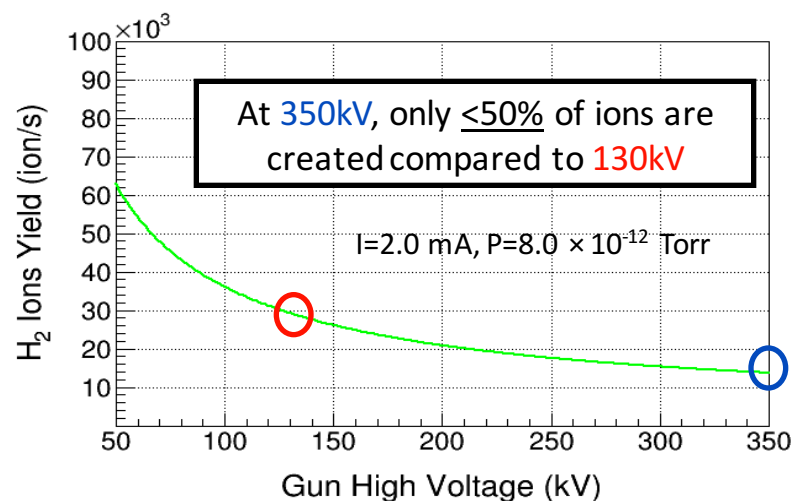
- *QE is now a factor 6 larger*
- *Potential for higher currents*
- *Less laser power, less heat to dissipate*
- *Quite complex structure*

**THE LAST LAYER IS A HIGHLY
P-DOPED BULK GaAs
ACTIVATED WITH Cs-O**

- NEA is achieved and can be maintained only in extreme vacuum
 - XHV require massive pumping to reach **10^{-12} Torr**;
- Ions backstreaming is still limiting operating lifetime
 - Clearing electrodes and or biased anode;
 - Higher gun voltages;



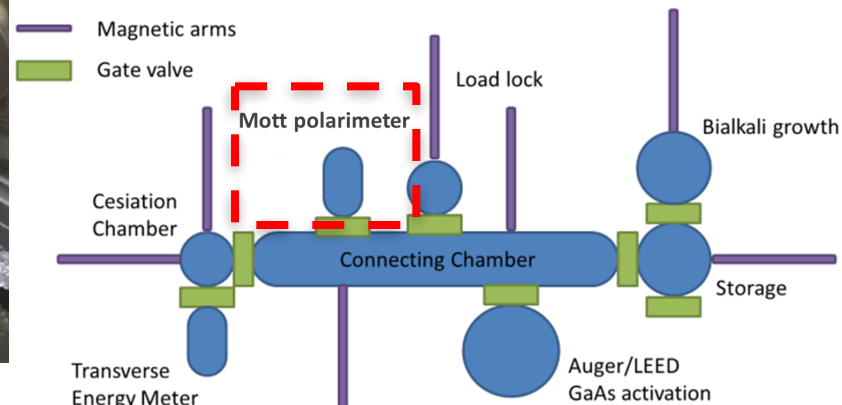
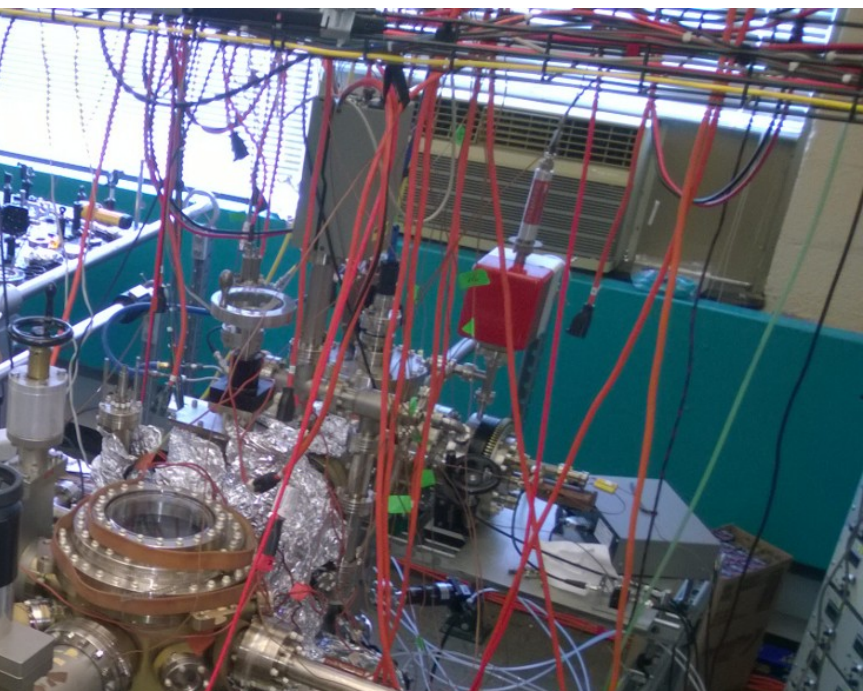
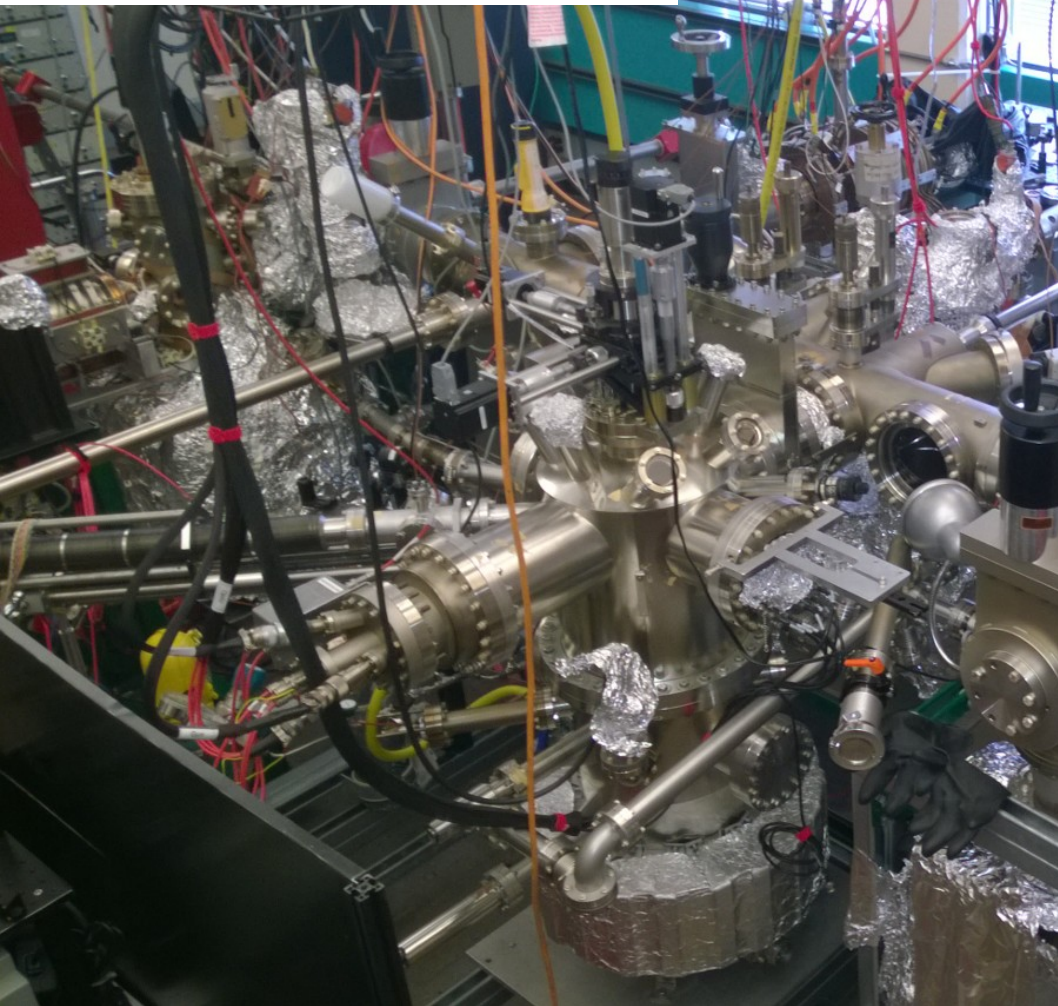
*A single HV breakdown event inside the gun
Can get the vacuum high enough to instantly
“kill” the cathode*



Courtesy of J. Grames



Vacuum level is below 10^{-10} Torr

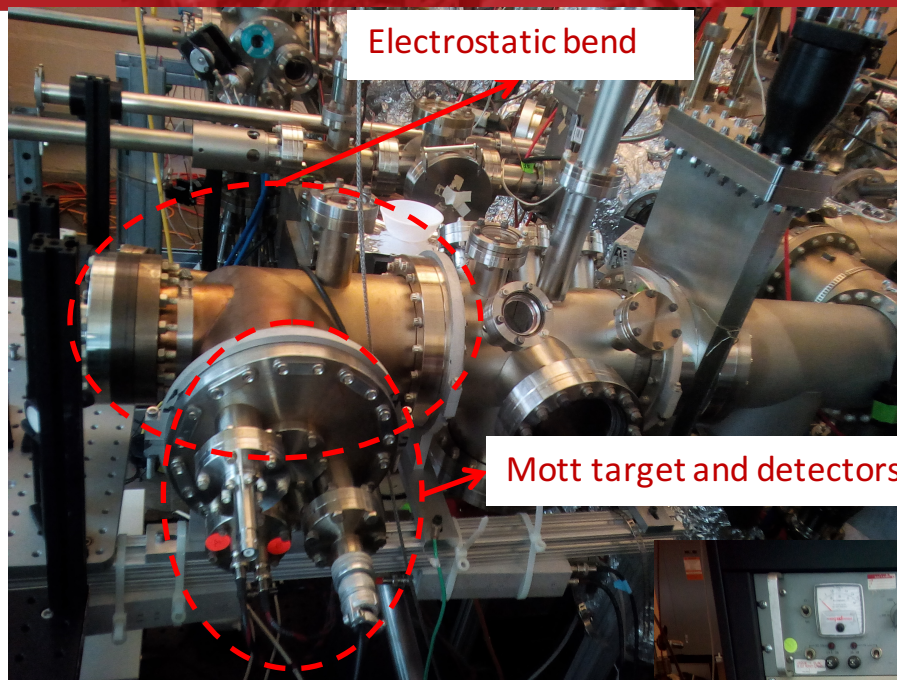
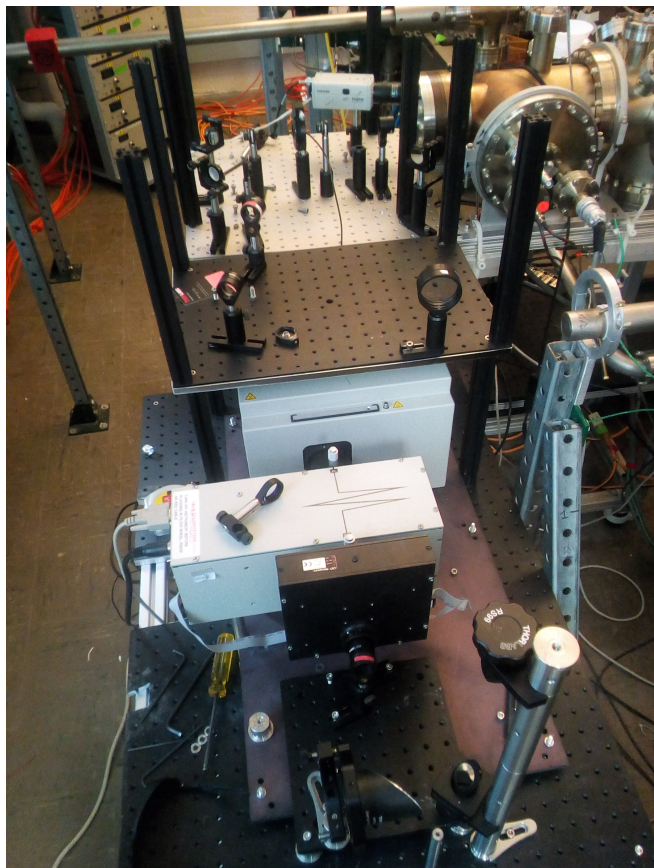




Cornell Laboratory for
Accelerator-based Sciences and
Education (CLASSE)

Mott polarimeter @ CU

Vacuum level is below 10^{-10} Torr



**The retarding field Mott polarimeter has been
refurbished upgraded and fully integrated into the
photocathode lab UHV installation.**

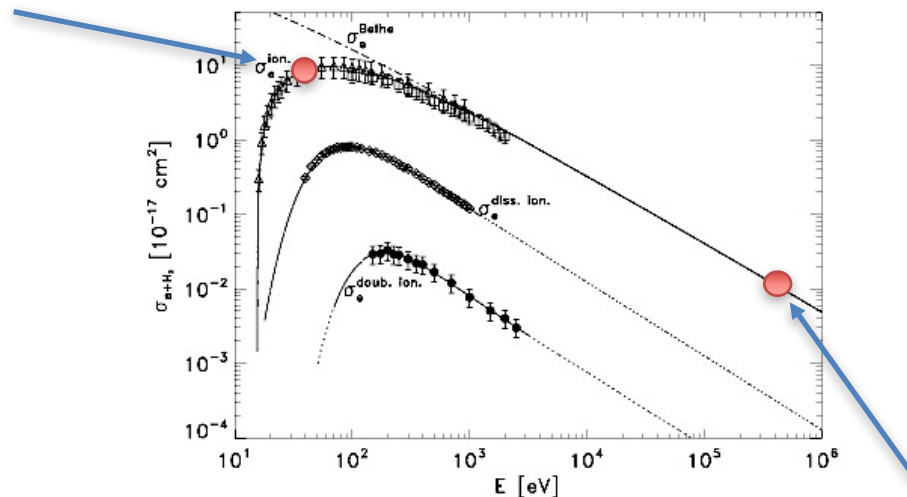
15-20 September 2019

ERL'19 - Berlin

**Thanks to M. Poelker and M. Stuzman for helping
in debugging and setting up the polarimeter**

- Following measurements are performed:
 - At Very low electric field (bias -36 V);
 - With small cw laser diodes (tens of μW);
 - At vacuum levels of $\sim 5 \times 10^{-11}$ Torr;

Beam energy in our setup is about 36 eV

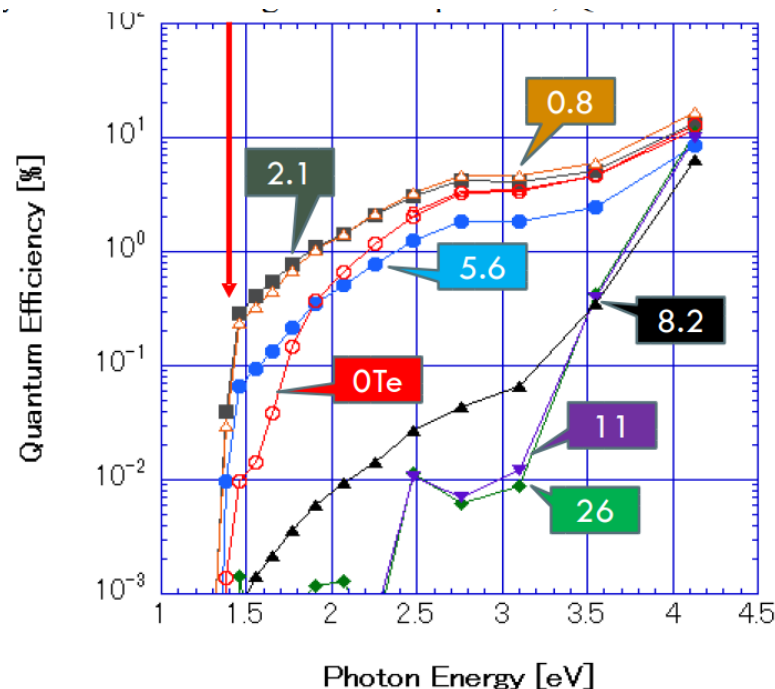
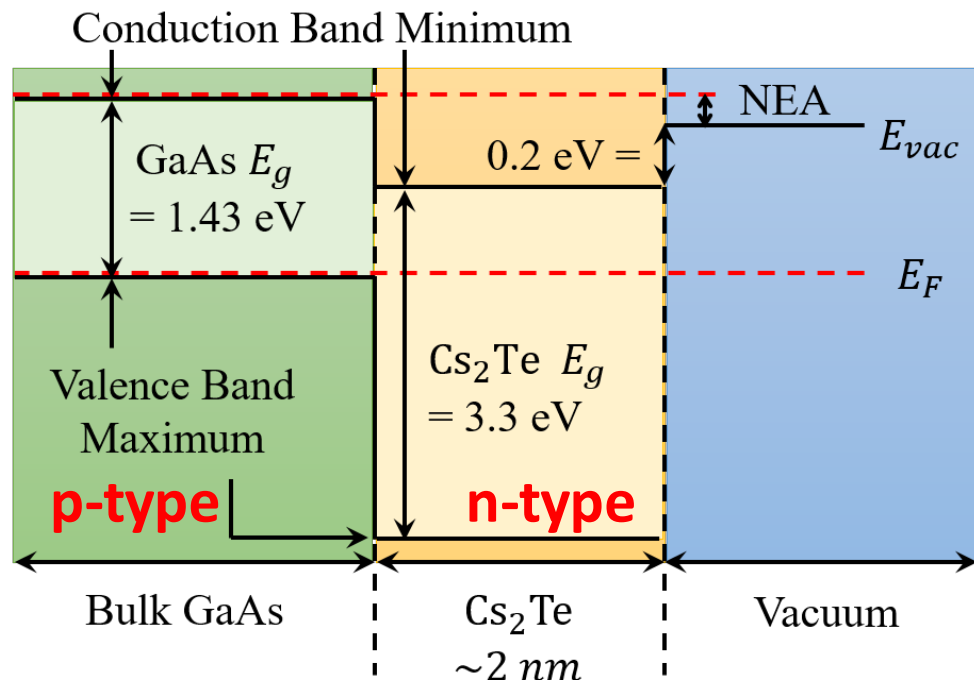


Beam energy in CU gun

- About 3 order of magnitude larger probability to ionize hydrogen than in a real gun
- Due to low energy electron the ion back bombardment damage is likely to affect the very surface of our samples.

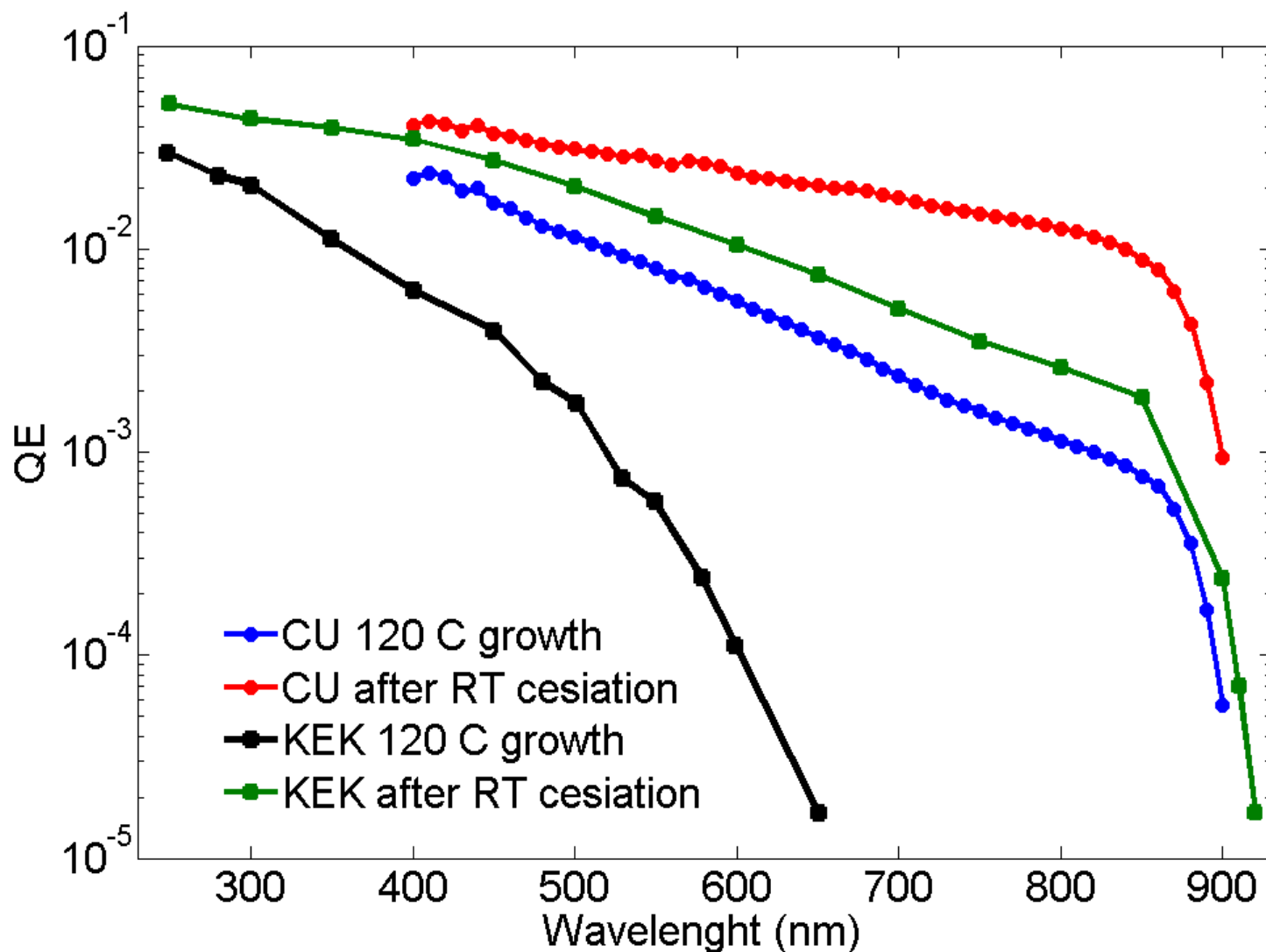
Cs₂Te on GaAs

M. Kuriki, P3 workshop, LBNL, 2014



Will this method yield longer lifetimes?

What happen to the spin polarization?

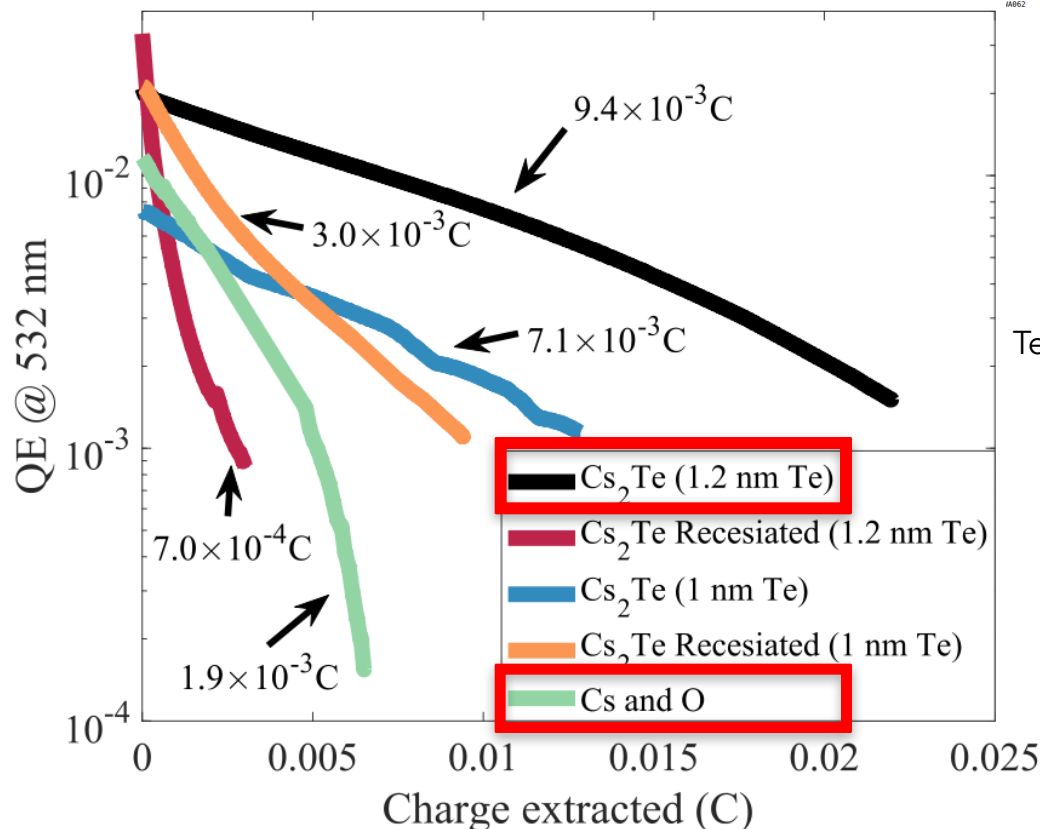


Cs₂Te and CsKTe on GaAs

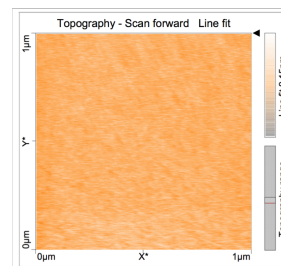
O. Rahman et al., IPAC 2019, TUPTS102

5X LIFETIME!

@532 nm



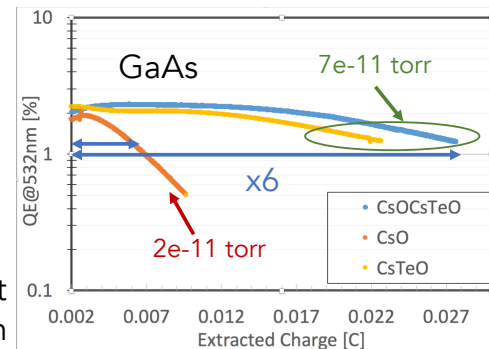
J. Bae et al., Appl. Phys. Lett. **112** (2018) 154101



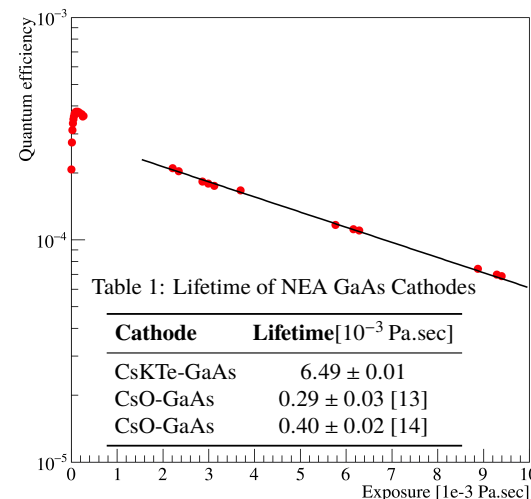
540 °C heat treatment
Roughness: 1.8-3.9 nm



Te source in Saes dispenser

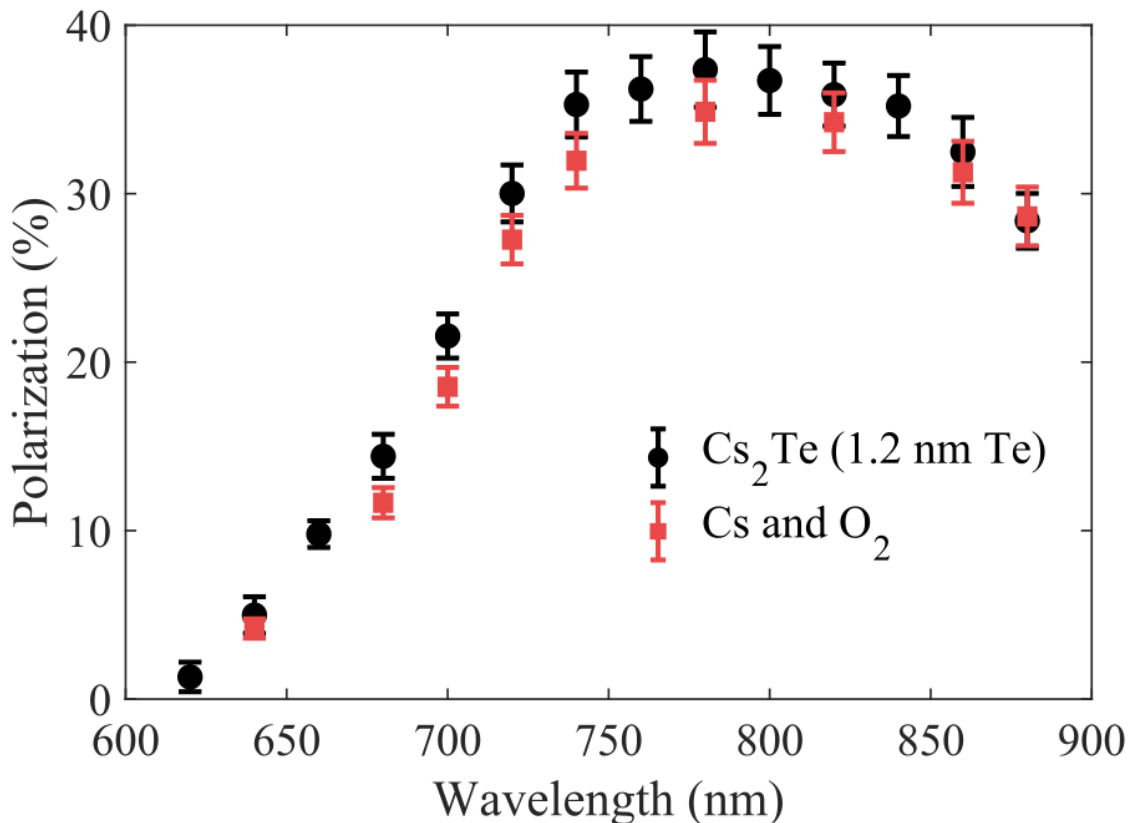


Trying GaAs/GaAsP
and CsI coating now.



M. Kuriki et al., IPAC 2019, TUPTS026

The same GaAs wafer was activated first with Cs-O and later with Cs₂Te



**Spin polarization is
not affected by the
Cs₂Te surface layer**

APPLIED PHYSICS LETTERS 112, 154101 (2018)



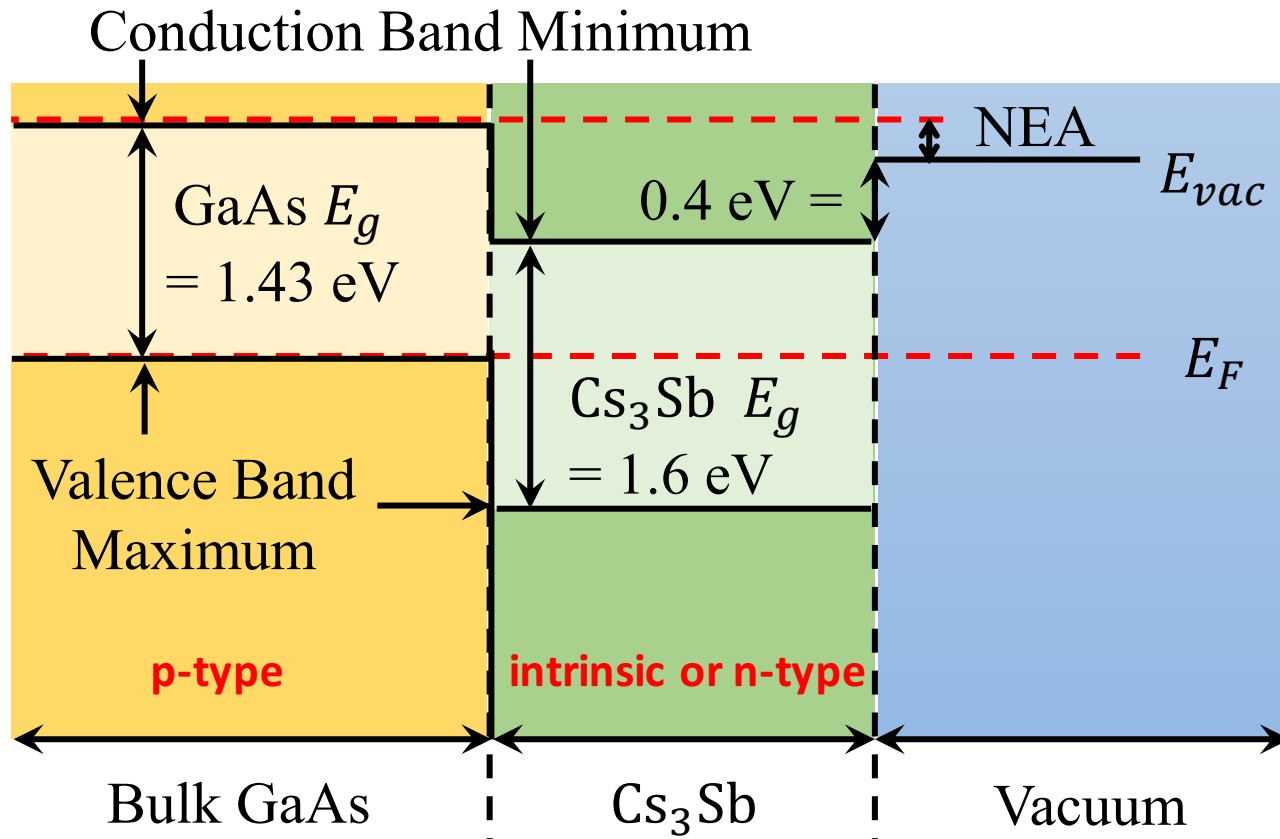
**Rugged spin-polarized electron sources based on negative electron affinity
GaAs photocathode with robust Cs₂Te coating**

Jai Kwan Bae, Luca Cultrera, Philip DiGiacomo, and Ivan Bazarov
Cornell Laboratory for Accelerator-Based Sciences and Education, Cornell University, Ithaca,
New York 14853, USA

(Received 22 February 2018; accepted 24 March 2018; published online 9 April 2018)

Cs₃Sb on GaAs

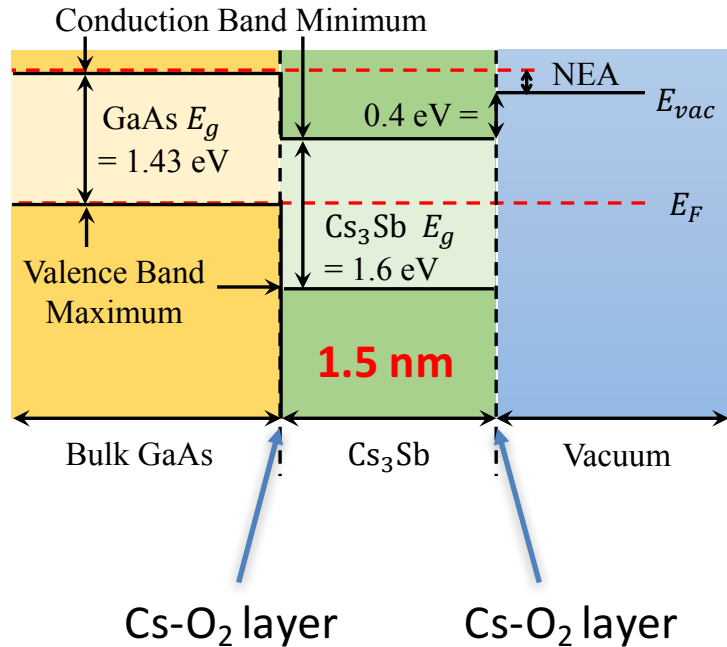
Doping control in alkali based photocathodes materials is difficult



Doping character is controlled by the stoichiometry

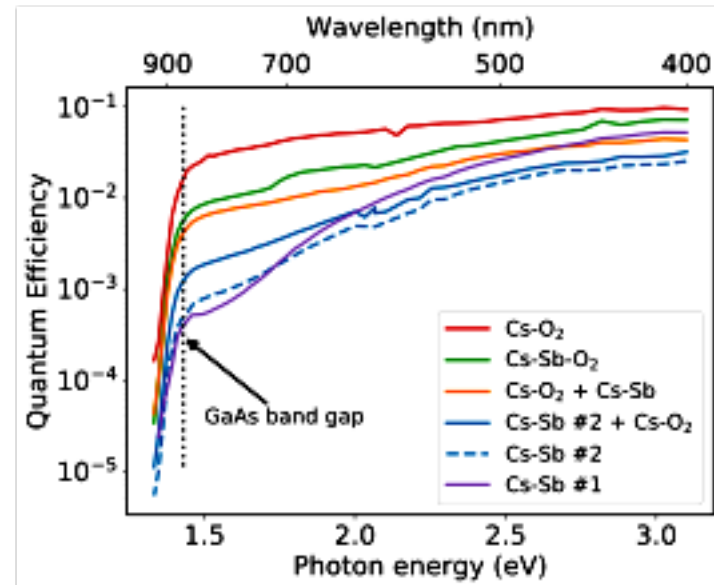
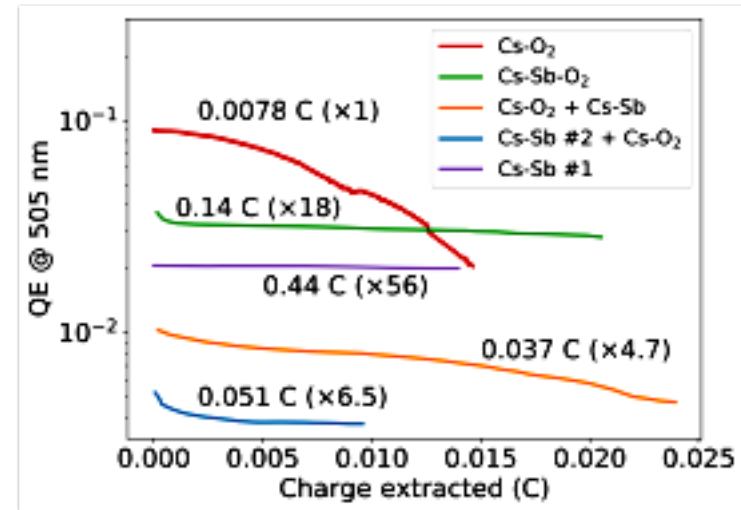
Cs₃Sb on GaAs - Methods

J. Bae et al, NAPAC 2019, MOPLH17

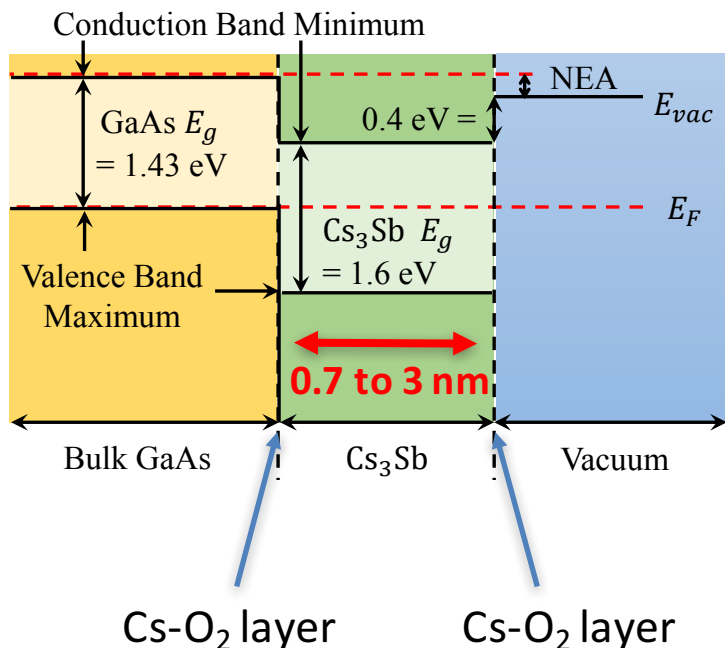


All the methods allowed reaching NEA co-deposition of Cs-Sb-O₂ allow:

- the longer lifetimes (x20)
- and the higher QE (1/2 of Cs-O)

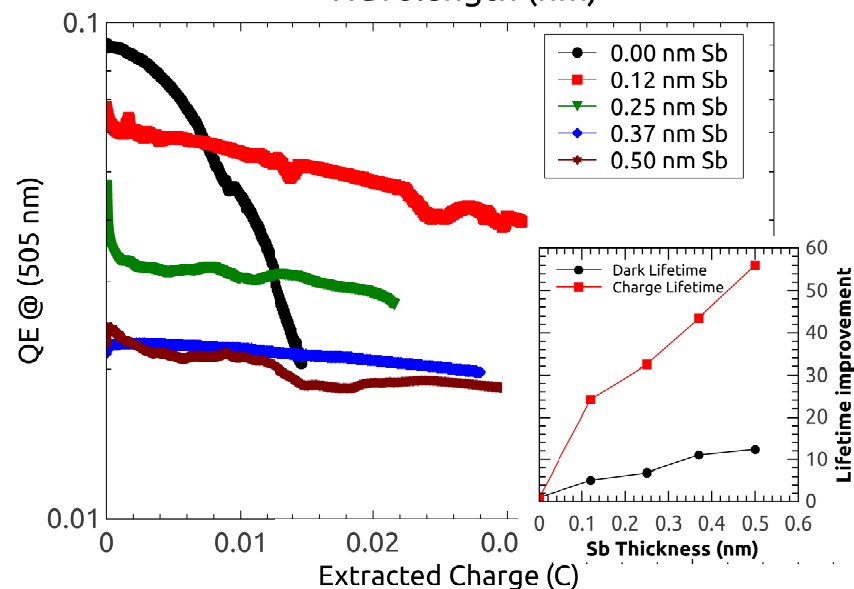
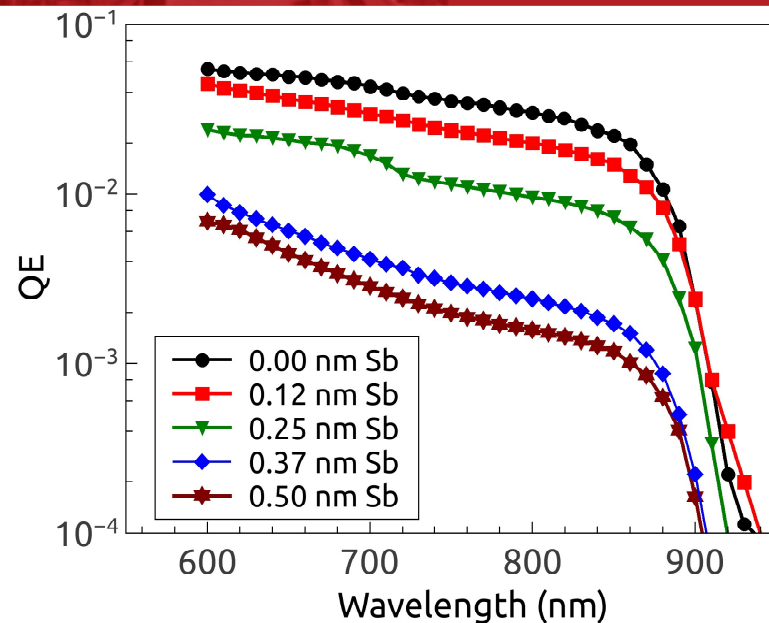


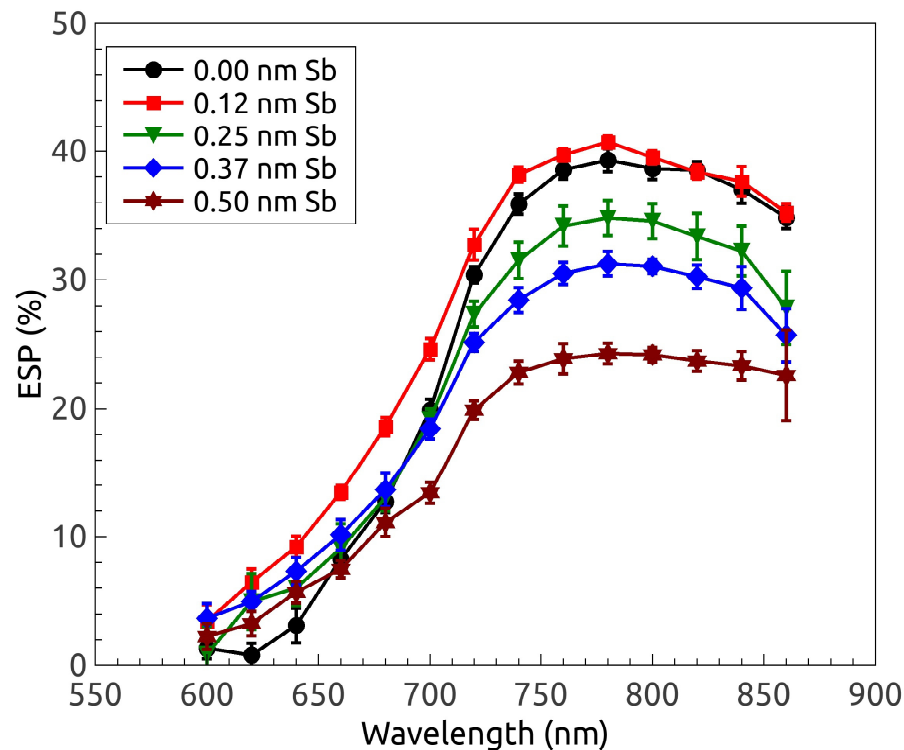
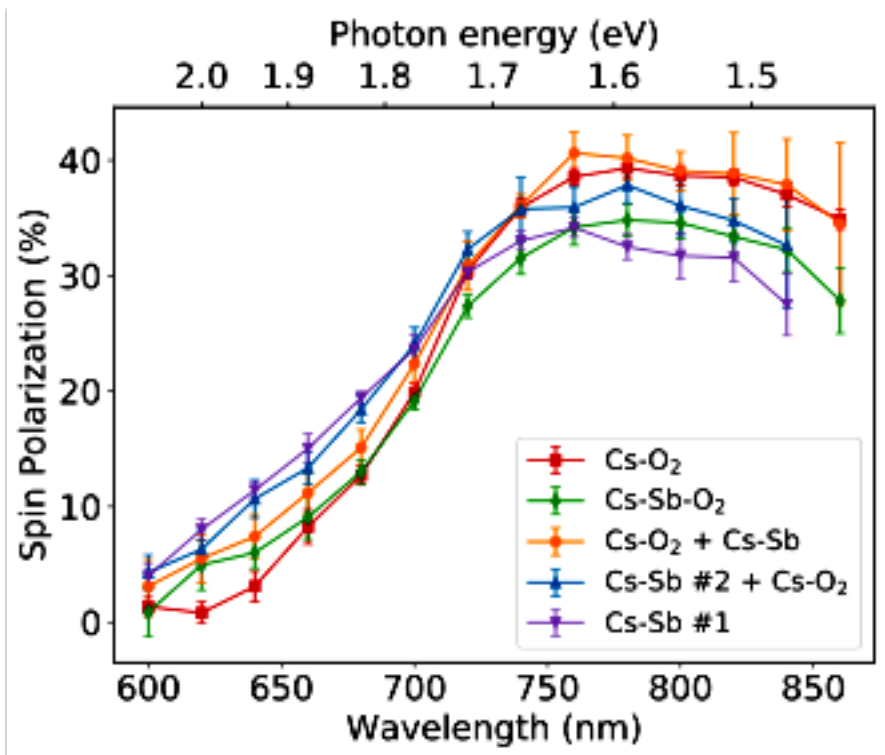
Cs₃Sb on GaAs - Thickness



as we increase the layer thickness:

- QE decreases
- Lifetime increases





**Spin polarization is essentially preserved
(up to 1 nm thickness)**

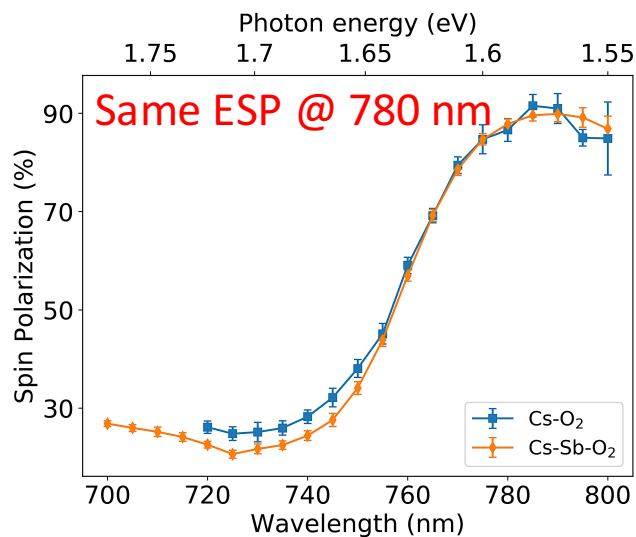
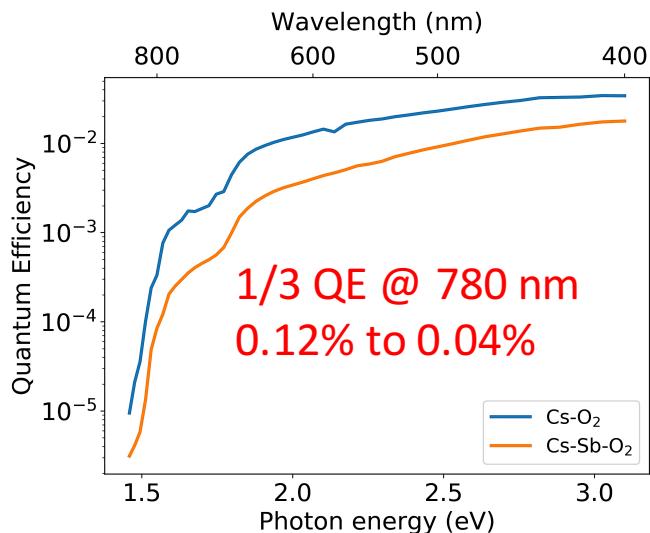


**Can all of this be
applied from bulk GaAs
to high polarization
photocathodes?**

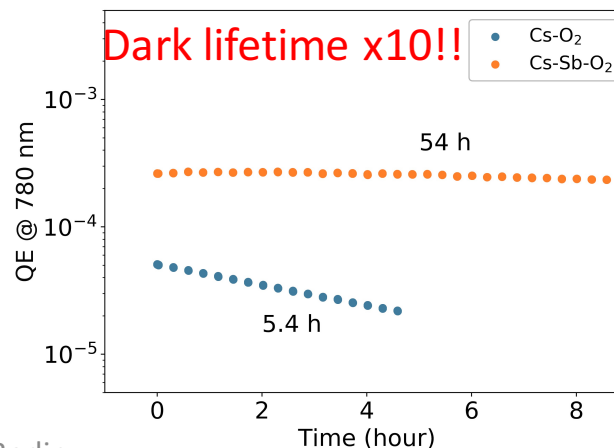
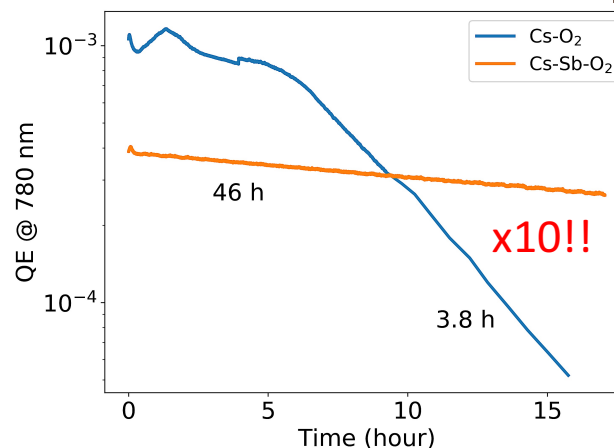


YES!!

- Preliminary results!

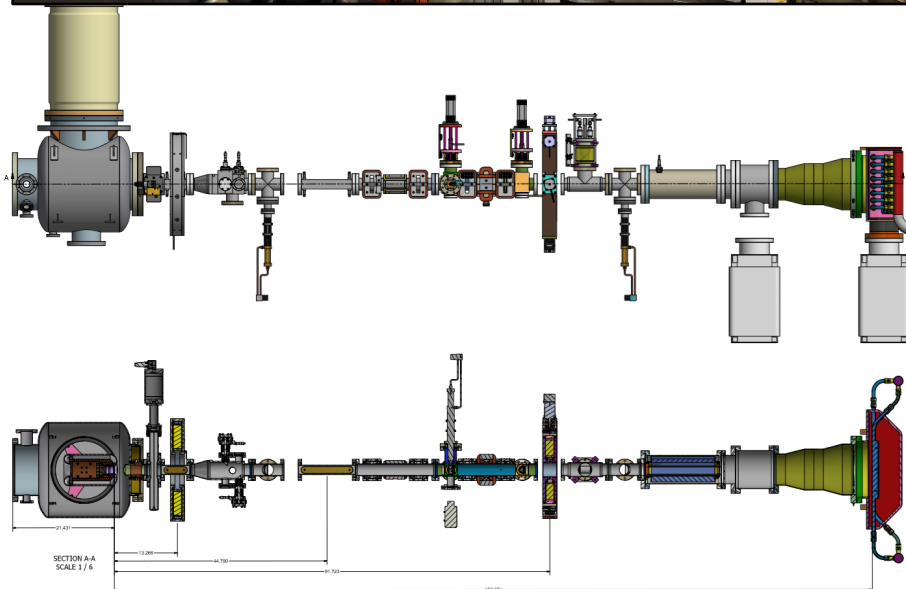
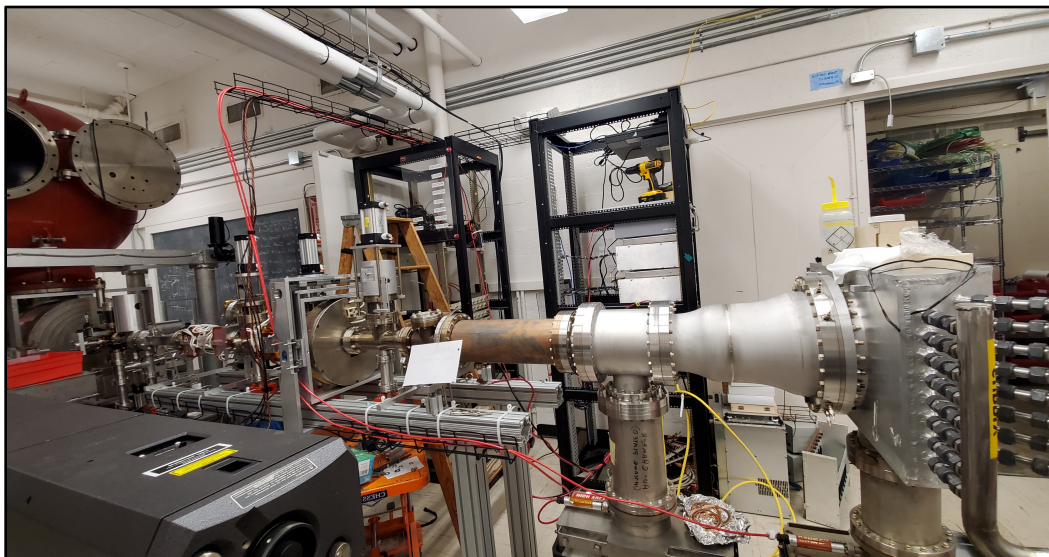


SL GaAs/GaAsP non DBR
with P>80% @780nm
From Jlab injector group
Activated with 0.12 nm Sb





Next?: High power cathode test



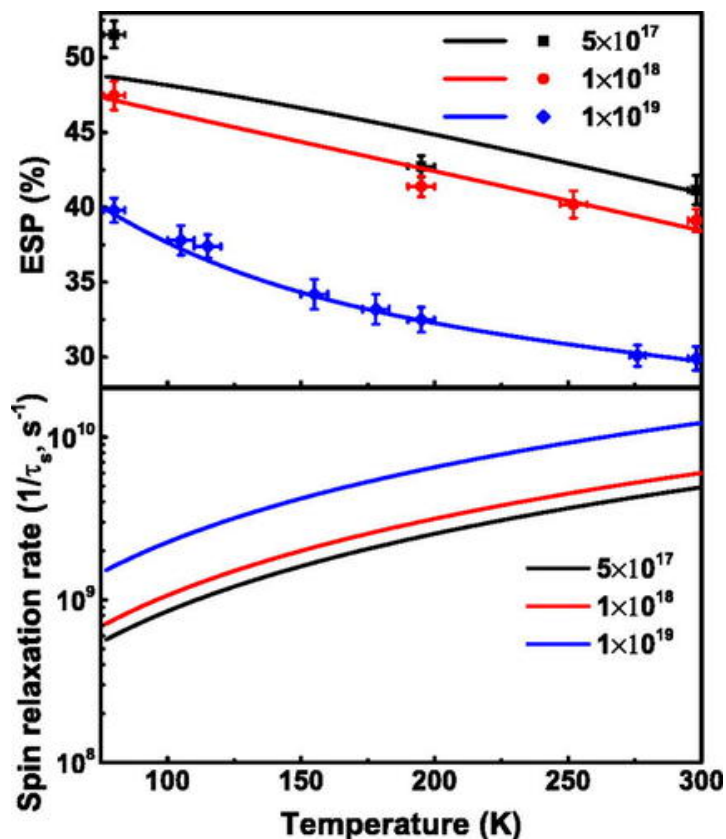
We are completing the installation of
a dedicated beamline:

- Old CU-ERL gun 400kV @ 100 mA;
- Ion clearing electrodes;
- High power lasers;
- 75 kW beam dump;

ESP can be increased at low temperatures



REVIEW OF SCIENTIFIC INSTRUMENTS **89**, 083303 (2018)



JOURNAL OF APPLIED PHYSICS **122**, 035703 (2017)

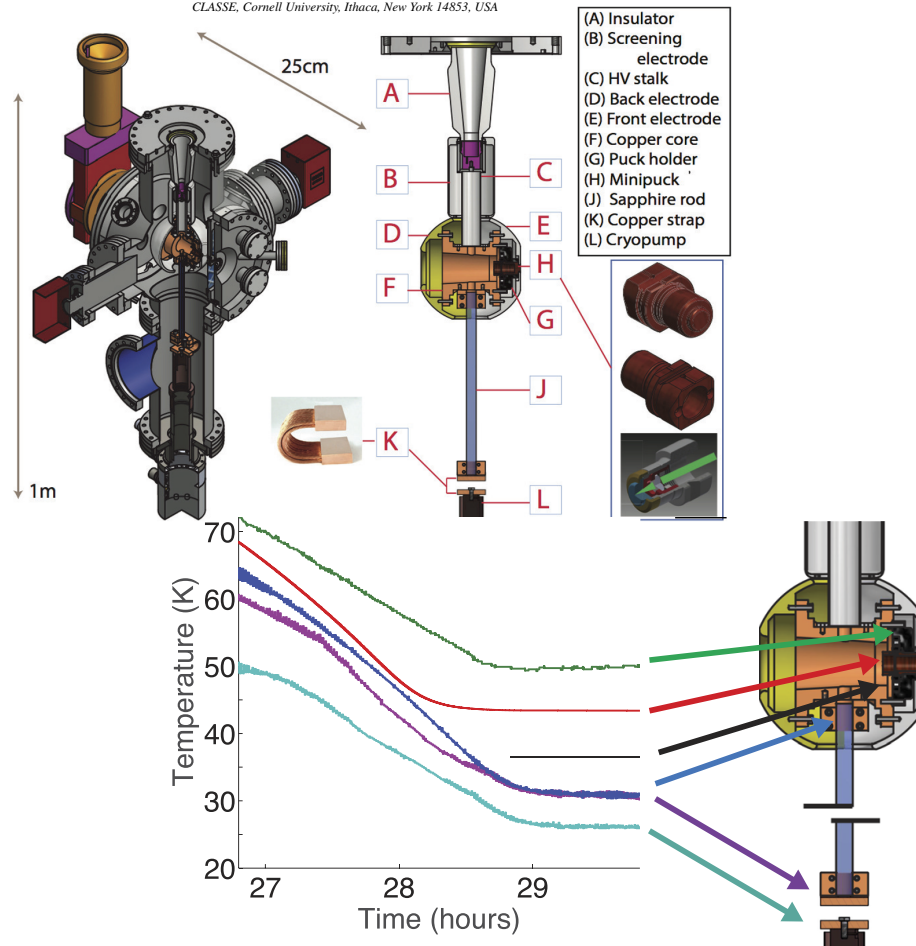


A comprehensive evaluation of factors that influence the spin polarization of electrons emitted from bulk GaAs photocathodes

Wei Liu,^{1,2,3} Matt Poelker,³ Xincun Peng,^{3,4} Shukui Zhang,³ and Marcy Stutzman³
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³Thomas Jefferson National Accelerator Facility, 12000 Jefferson Avenue, Newport News, Virginia 23606, USA
⁴Engineering Research Center of New Energy Technology of Jiangxi Province, East China Institute of Technology, Nanchang 330013, China

A cryogenically cooled high voltage DC photoemission electron source

Hyeri Lee,^{a)} Xianghong Liu, Luca Cultrera, Bruce Dunham,^{b)} Vaclav O. Kostroun, and Ivan V. Bazarov
 CLASSE, Cornell University, Ithaca, New York 14853, USA





- The use of alternative coatings to activate GaAs based photocathodes:
 - NEA can be achieved with either Cs-Te and Cs-Sb;
 - Lifetime is improved by a factor of 10x or more;
 - Polarization and QE are affected by thickness;
 - Trades off are required;
- Soon beam tests in a real gun;
- Cryogenic electron sources can be leveraged to increase polarization.
- kCoulomb from PES in sight?



Thank you for the attention!!

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collaborators:

Ivan Bazarov, Jared Maxson

Alice Galdi, Jai Kwan Bae, Frank Ikponmwon

And the photocathode development group at CLASSE